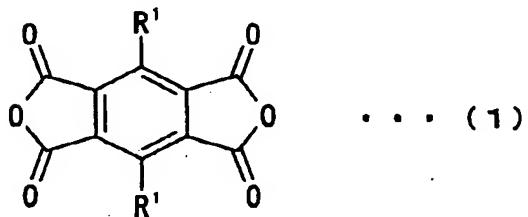


WHAT IS CLAIMED IS :

1. A polyimide film having a dynamic viscoelasticity whose tan  $\delta$  peak is located in a range of not less than  $310^{\circ}\text{C}$  but not more than  $410^{\circ}\text{C}$ , and whose tan  $\delta$  value at  $300^{\circ}\text{C}$  is not more than 0.05.
2. The polyimide film as set forth in Claim 1, the polyimide film prepared by copolymerizing an acid dianhydride component and a diamine component, the acid dianhydride component including a pyromellitic dianhydride represented by Equation (1):

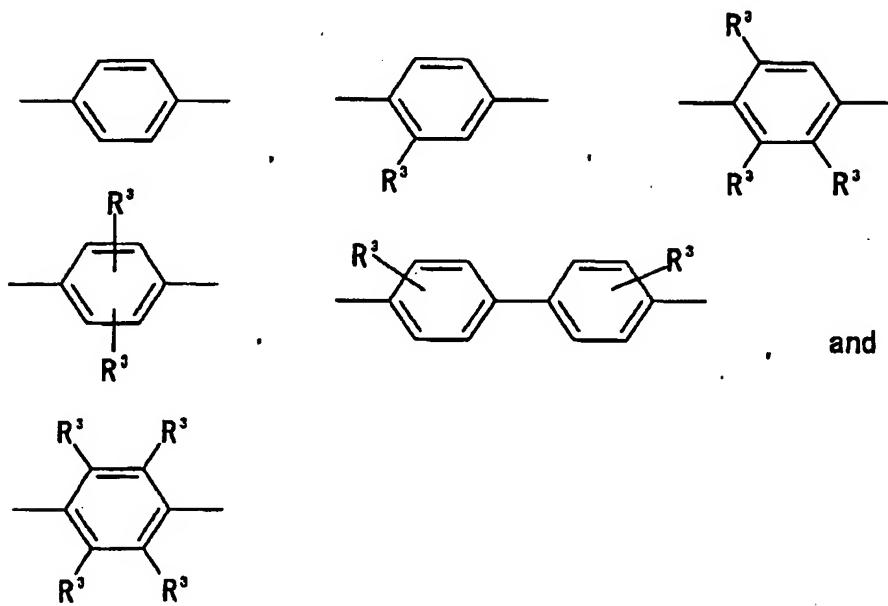


(where  $\text{R}^1$  is a residue selected from a group consisting of  $\text{H-}$ ,  $\text{CH}_3-$ ,  $\text{CF}_3-$ ,  $\text{Cl-}$ ,  $\text{Br-}$ ,  $\text{F-}$ , and  $\text{CH}_3\text{O-}$ , and  $\text{R}^1$  may be the same residues or different residues), and the diamine component including a paraphenylene diamine and a diaminodiphenyl ether,

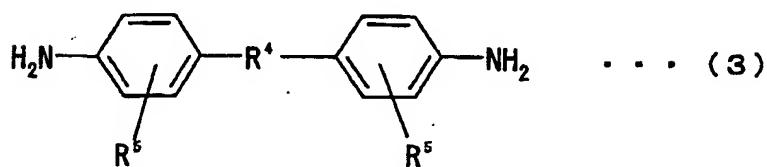
the paraphenylene diamine being represented by Equation (2):



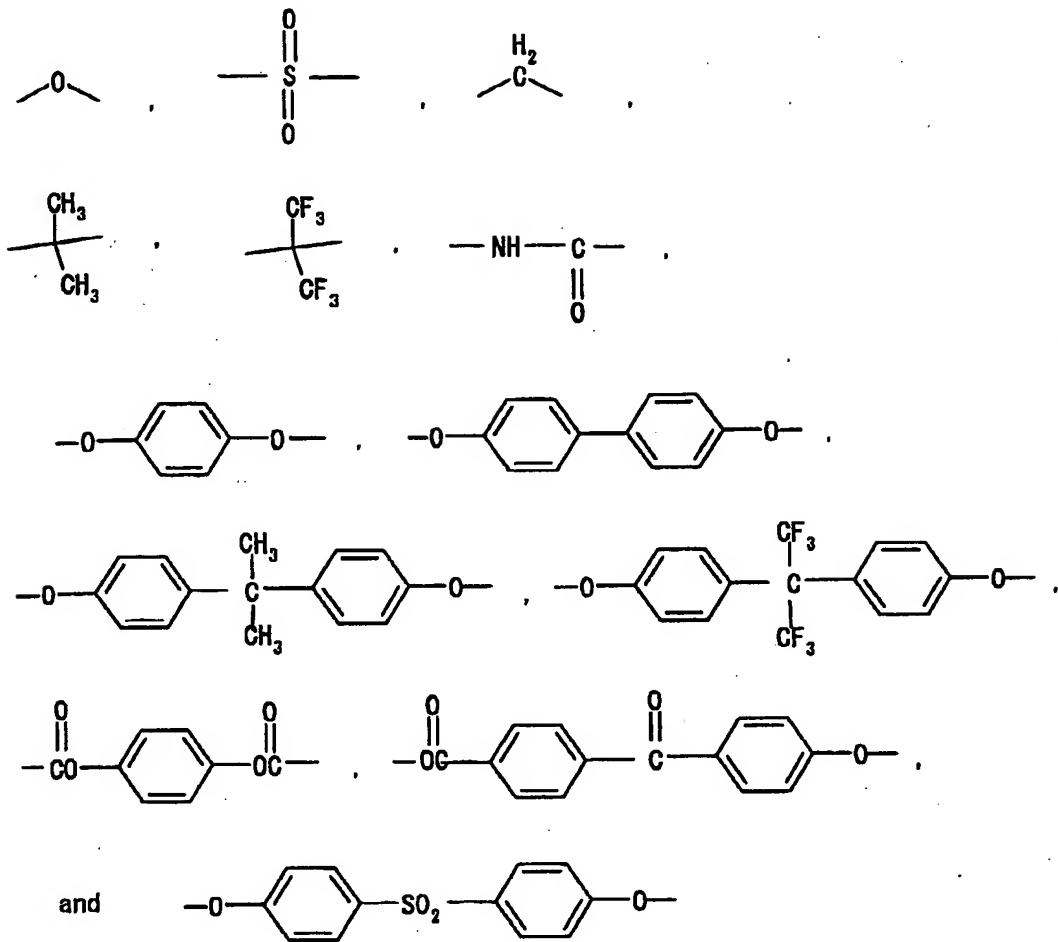
(where  $\text{R}^2$  is a bivalent aromatic group selected from a group consisting of:



and each  $\text{R}^3$  in the group is independently any one of -H, - $\text{CH}_3$ , -OH, - $\text{CF}_3$ , - $\text{SO}_4$ , -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>), and the diaminodiphenyl ether being represented by General Formula (3):



(where  $R^4$  is a bivalent organic group selected from a group consisting of:



and each  $R^5$  in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>).

3. The polyimide film as set forth in Claim 2,  
wherein:

the acid dianhydride component includes the pyromellitic dianhydride in a range of from 5 mole% to 90 mole%.

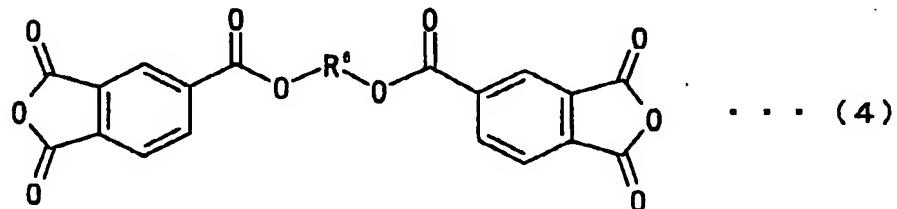
4. The polyimide film as set forth in Claim 2,  
wherein:

the diamine component includes the paraphenylene diamine in a range of from 25 mole% to 75 mole%, and diaminodiphenyl ether in a range of from 25 mole% to 75 mole%.

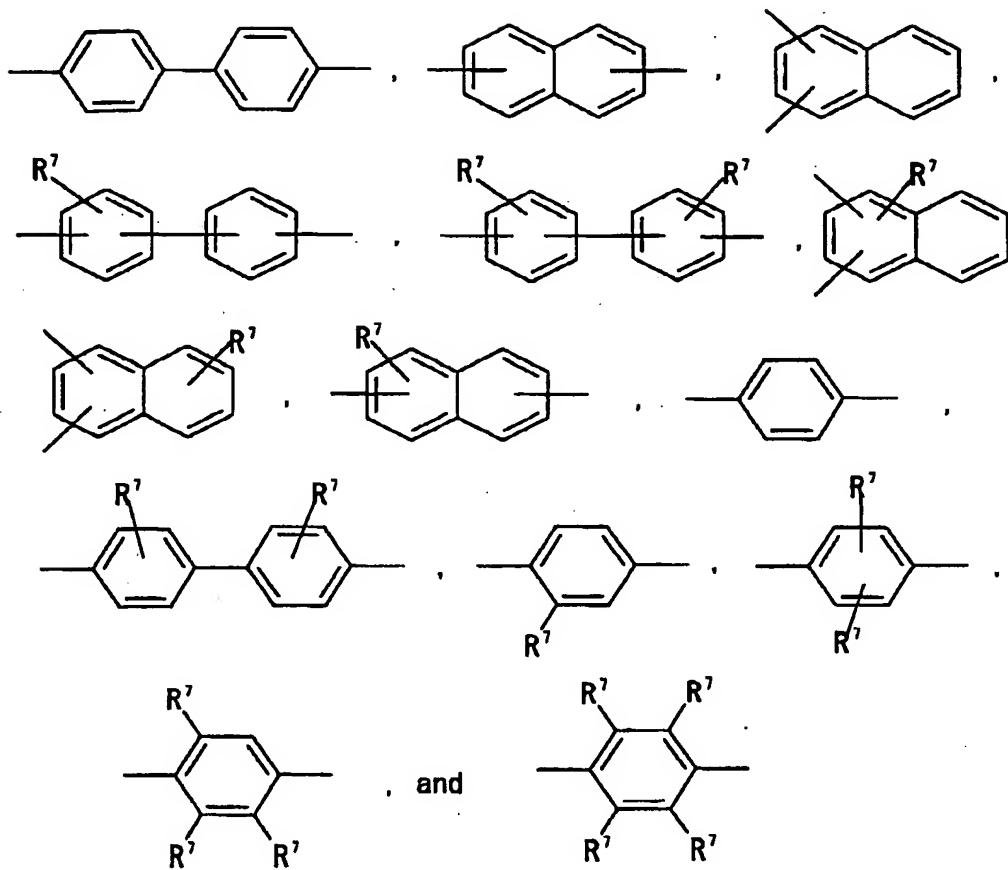
5. The polyimide film as set forth in Claim 2,  
wherein:

the acid dianhydride component further includes a bis(trimellitic monoester anhydride) and/or a biphenyl tetracarboxylic dianhydride,

the bis(trimellitic monoester anhydride) being represented by General Formula (4):

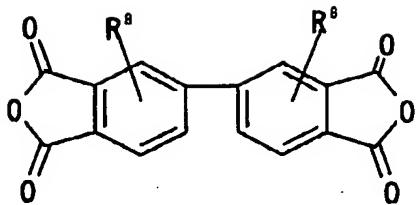


(where  $R^6$  is a bivalent organic group selected from a group consisting of:



and each  $R^7$  is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, and -CO-NH<sub>2</sub>), and

the biphenyl tetracarboxylic dianhydride being represented by General Formula (5):



• • • (5)

(where  $R^8$  is a residue selected from a group consisting of H-,  $CH_3$ -, Cl-, Br-, F- and  $CH_3O$ -, and  $R^8$  may be the same residues or the different residues).

6. The polyimide film as set forth in Claim 5, wherein the acid dianhydride component includes the bis(trimellitic monoester anhydride) in a range of from 20 mole% to 40 mole%.

7. The polyimide film as set forth in Claim 5, wherein the acid dianhydride component includes the biphenyl tetracarboxylic dianhydride in a range of from 0 mole% to 50 mole%.

8. The polyimide film as set forth in Claim 1,  
wherein:

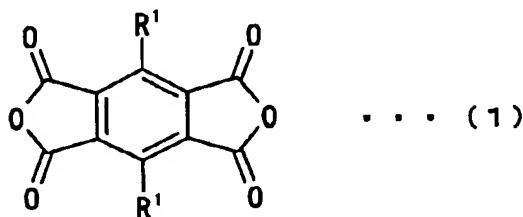
a coefficient of hygroscopic expansion is 16ppm/%RH or less, and a water absorption percentage is 2.0% or less.

## 9. Laminate comprising:

a metal layer; and

a polyimide film having a dynamic viscoelasticity whose tan  $\delta$  peak is located in a range of not less than 310°C but not more than 410°C, and whose tan  $\delta$  value at 300°C is not more than 0.05.

10. The laminate as set forth in Claim 9, wherein:  
the polyimide film is prepared by copolymerizing an acid dianhydride component and a diamine component,  
the acid dianhydride component including a pyromellitic dianhydride represented by Equation (1):

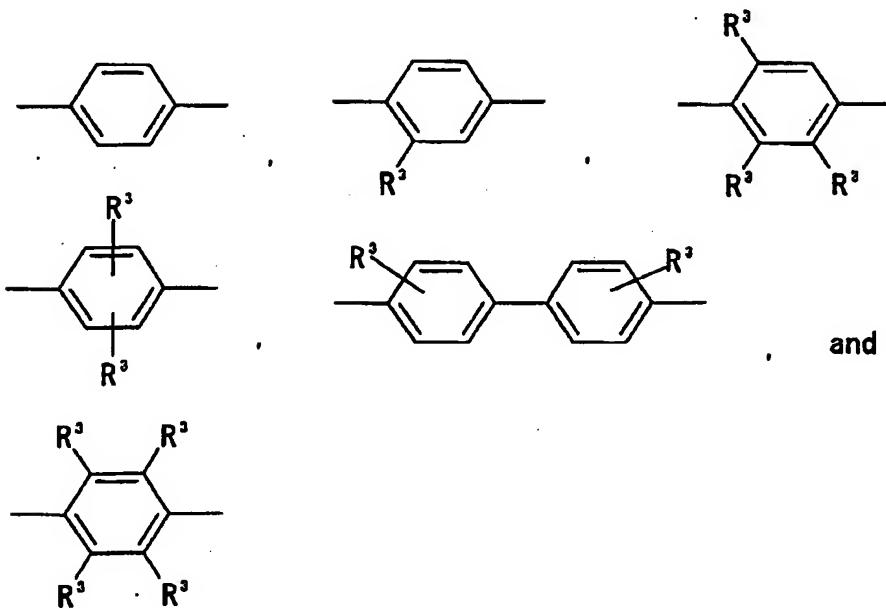


(where  $R^1$  is a residue selected from a group consisting of H-,  $CH_3$ -,  $CF_3$ -,  $Cl$ -,  $Br$ -,  $F$ -, and  $CH_3O$ -, and  $R^1$  may be the same residues or different residues), and

the diamine component including a paraphenylene diamine and a diaminodiphenyl ether,  
the paraphenylene diamine being represented by Equation (2):

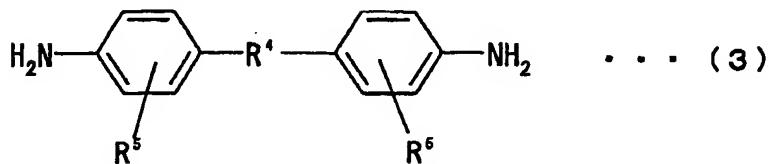


(where  $\text{R}^2$  is a bivalent aromatic group selected from a group consisting of:

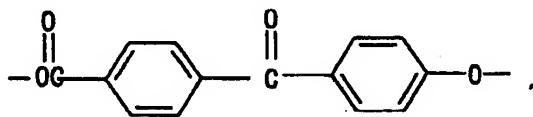
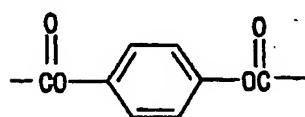
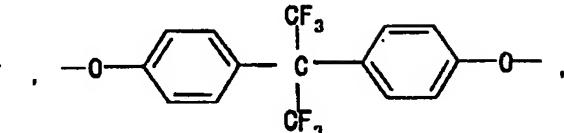
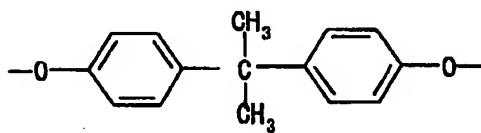
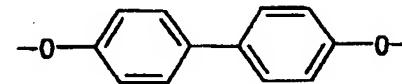
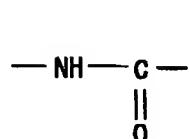
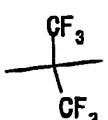
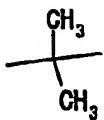
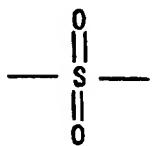
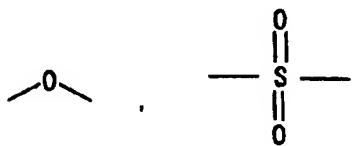


and each  $\text{R}^3$  in the group is independently any one of -H, - $\text{CH}_3$ , -OH, - $\text{CF}_3$ , - $\text{SO}_4$ , -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>), and

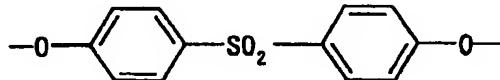
the diaminodiphenyl ether being represented by General Formula (3):



(where  $R^4$  is a bivalent organic group selected from a group consisting of:



and

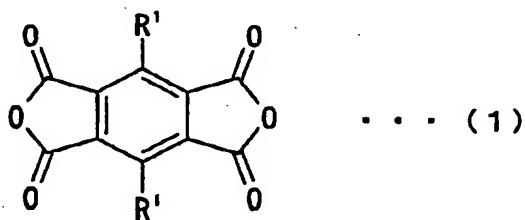


and each  $R^5$  in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>).

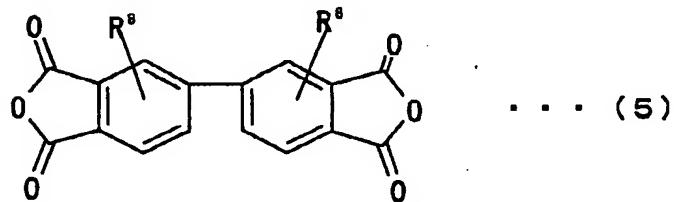
11. A polyimide film prepared by copolymerizing an acid dianhydride component and a diamine component,

the acid dianhydride component including a pyromellitic dianhydride and a biphenyl tetracarboxylic dianhydride,

the pyromellitic dianhydride being represented by General Formula (1):



(where  $R^1$  is a residue selected from a group consisting of  $H^-$ ,  $CH_3^-$ ,  $CF_3^-$ ,  $Cl^-$ ,  $Br^-$ ,  $F^-$ , and  $CH_3O^-$ , and  $R^1$  may be the same residues or different residues), and the biphenyl tetracarboxylic dianhydride being represented by General Formula (5):



(where  $R^2$  is a residue selected from a group consisting of  $H^-$ ,  $CH_3^-$ ,  $Cl^-$ ,  $Br^-$ ,  $F^-$  and  $CH_3O^-$ , and  $R^2$  may be the same

residues or the different residues), and

the polyimide film having such an etching speed that one side thereof is etched with a 1N potassium hydroxide solution at an etching speed of  $0.1\mu\text{m}/\text{minute}$  (one side) or higher.

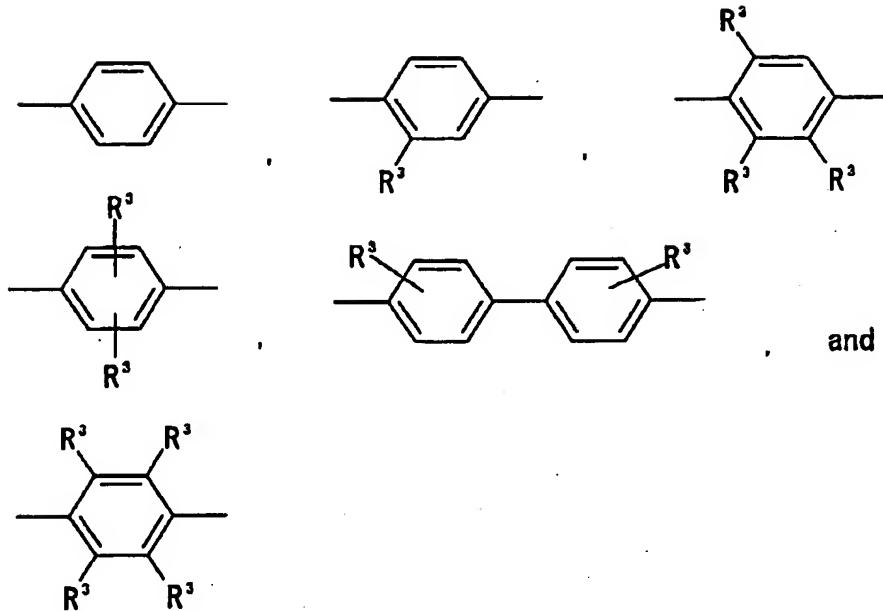
12. The polyimide film as set forth in Claim 11, wherein:

the diamine component includes a paraphenylene diamine and/or a diaminodiphenyl ether,

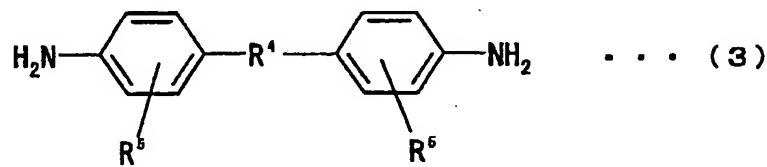
the paraphenylene diamine being represented by General Formula (2):



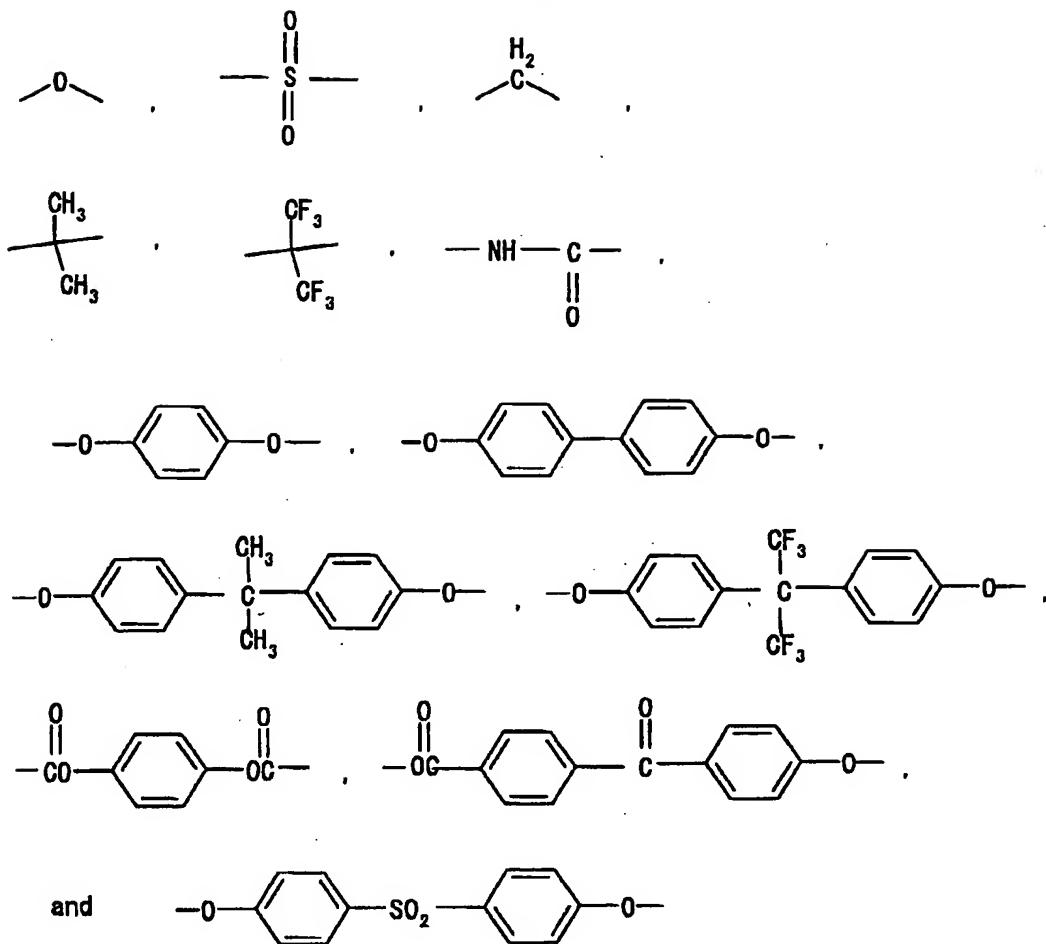
(where  $\text{R}^2$  is a bivalent aromatic group selected from a group consisting of:



and each R<sup>3</sup> in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>), and the diaminodiphenyl ether being represented by General Formula (3):



(where R<sup>4</sup> is a bivalent organic group selected from a group consisting of:



and each R<sup>5</sup> in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>).

13. The polyimide film as set forth in Claim 11, wherein:

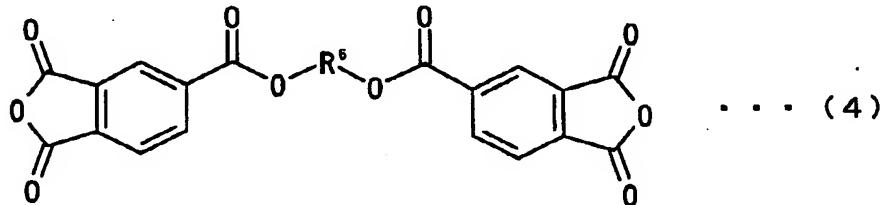
the acid dianhydride component includes the pyromellitic dianhydride in a range of from 30 mole% to

99.9 mole%, and the biphenyl tetracarboxylic dianhydride in a range of from 0.1 mole% to 50 mole%.

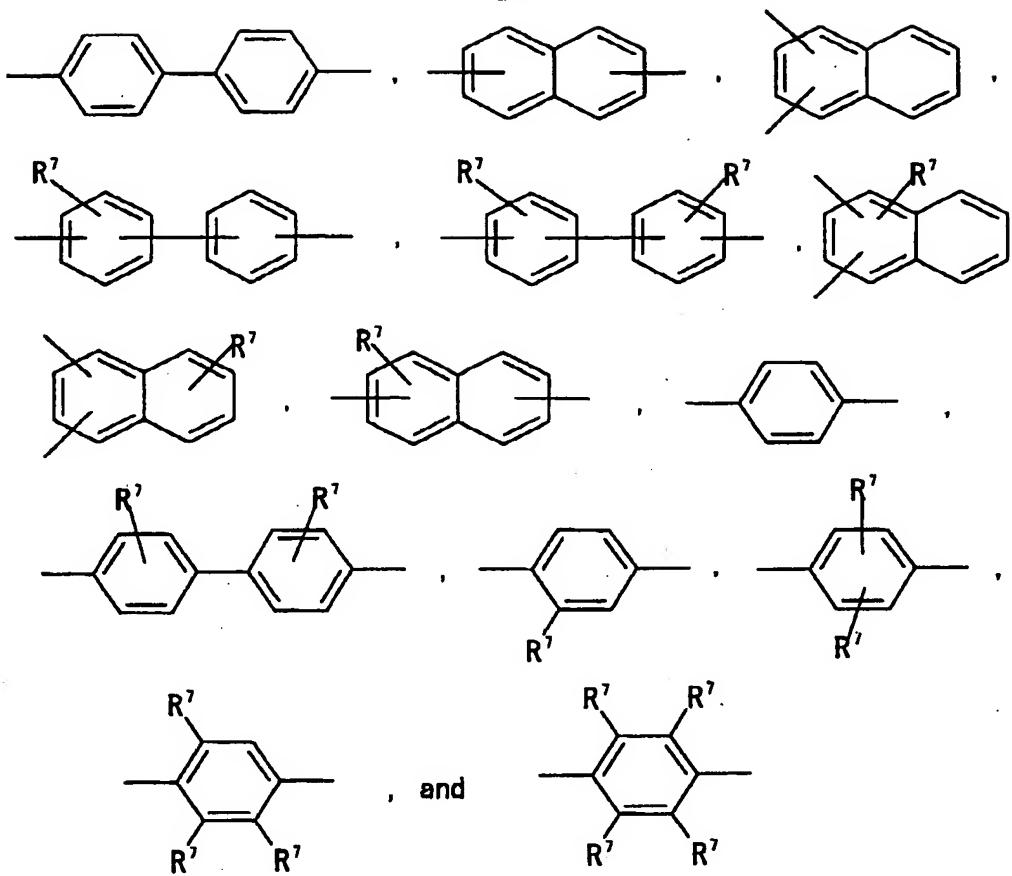
14. The polyimide film as set forth in Claim 12, wherein:

the diamine component includes the paraphenylene diamine in a range of from 15 mole% to 85 mole%, and diaminodiphenyl ether in a range of from 15 mole% to 85 mole%.

15. The polyimide film as set forth in Claim 12, the acid dianhydride component further includes a bis(trimellitic monoester anhydride) being represented by General Formula (4):



(where  $\text{R}^6$  is a bivalent organic group selected from a group consisting of:



and each R<sup>7</sup> is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, and -CO-NH<sub>2</sub>).

16. The polyimide film as set forth in Claim 15,  
wherein:

the acid dianhydride component includes the bis(trimellitic monoester anhydride) in a range of from 10 mole% to 50 mole%.

17. The polyimide film as set forth in Claim 11,  
wherein:

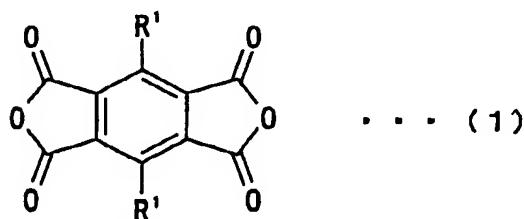
a retention percent of tear-through resistance of the polyimide film after exposing the polyimide film to environment of a temperature of 150°C, a humidity of 100%RH, and 4 atmospheric pressure for 48 hours is not less than 50%.

18. Laminate, comprising:

a metal layer; and

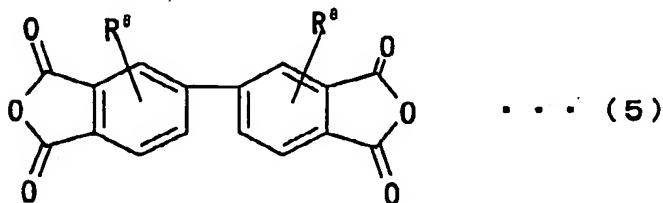
a polyimide film prepared by copolymerizing an acid dianhydride component and a diamine component,

the acid dianhydride component including a pyromellitic dianhydride and a biphenyl tetracarboxylic dianhydride, the pyromellitic dianhydride being represented by General Formula (1):



(where  $R^1$  is a residue selected from a group consisting of H-,  $CH_3$ -,  $CF_3$ -, Cl-, Br-, F-, and  $CH_3O$ -, and  $R^1$  may be the same residues or different residues), and

the biphenyl tetracarboxylic dianhydride being represented by General Formula (5):



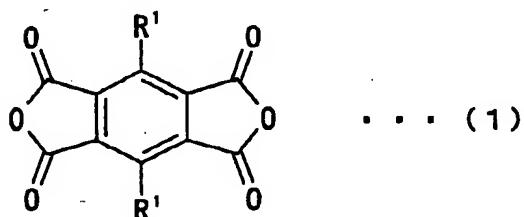
(where  $R^8$  is a residue selected from a group consisting of H-,  $CH_3$ -,  $Cl^-$ ,  $Br^-$ ,  $F^-$  and  $CH_3O^-$ , and  $R^8$  may be the same residues or the different residues), and

the polyimide film having such an etching speed that one side thereof is etched with a 1N potassium hydroxide solution at an etching speed of  $0.1\mu\text{m}/\text{minute}$  (one side) or higher.

19. A polyimide film prepared by copolymerizing an acid dianhydride component and a diamine component,

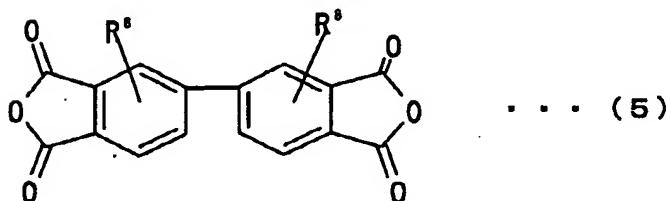
the acid dianhydride component including the pyromellitic dianhydride, represented by General Formula (1), in a range of from 40 mole% to 80 mole%, the biphenyl tetracarboxylic dianhydride, represented by General Formula (5) in a range of from 1 mole% to 40 mole%, and the bis(trimellitic monoester anhydride, represented by General Formula (4), in a range of from 20 mole% to 50 mole%, and

the diamine component including the paraphenylene diamine, represented by General Formula (2), in a range of 25 mole% to 75 mole%, and the diaminodiphenyl ether, represented by General Formula (3), in a range of 25 mole% to 75 mole%, where General Formula (1) is:



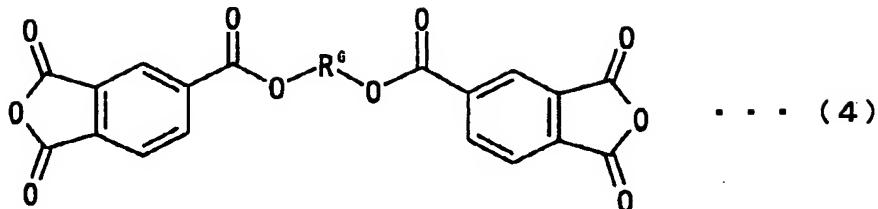
(where R¹ is a residue selected from a group consisting of H-, CH<sub>3</sub>-, CF<sub>3</sub>-, Cl-, Br-, F-, and CH<sub>3</sub>O-, and R¹ may be the same residues or different residues);

General Formula (5) is:

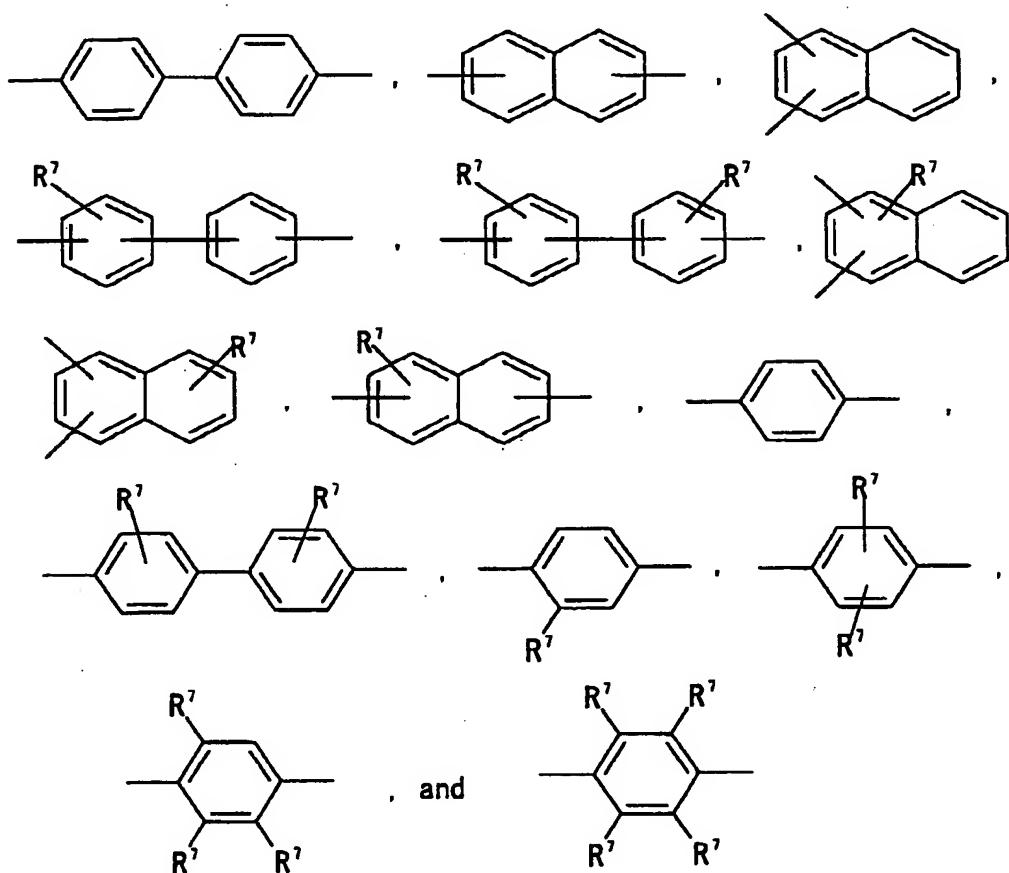


(where R⁸ is a residue selected from a group consisting of H-, CH<sub>3</sub>-, Cl-, Br-, F- and CH<sub>3</sub>O-, and R⁸ may be the same residues or the different residues);

General Formula (4) is:



(where  $R^6$  is a bivalent organic group selected from a group consisting of:

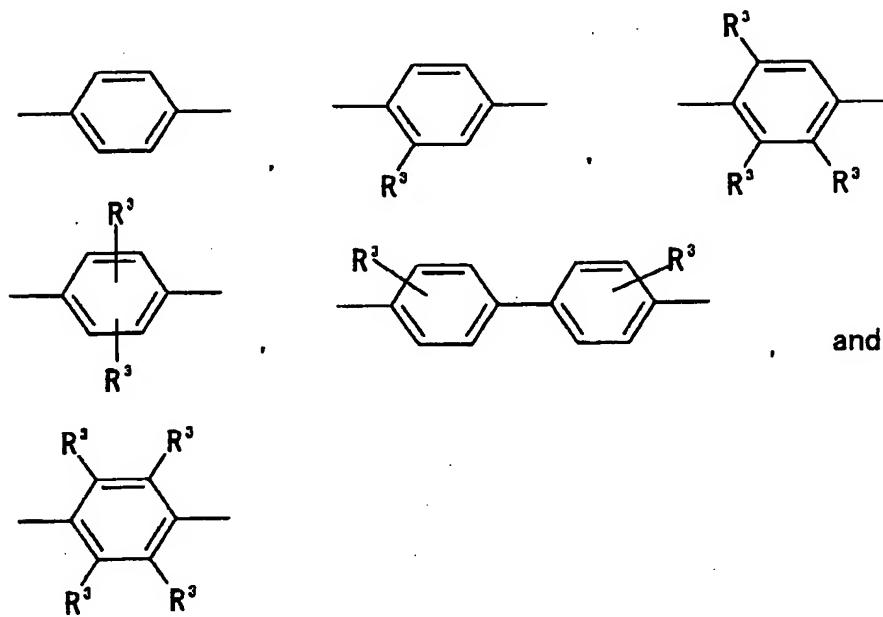


and each R<sup>7</sup> is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, and -CO-NH<sub>2</sub>);

General Formula (2) is:



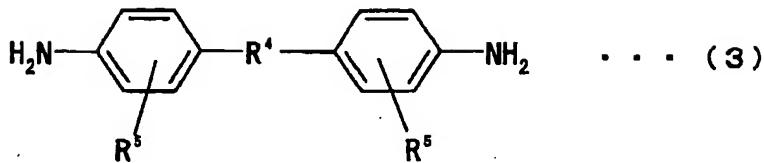
(where R<sup>2</sup> is a bivalent aromatic group selected from a group consisting of:



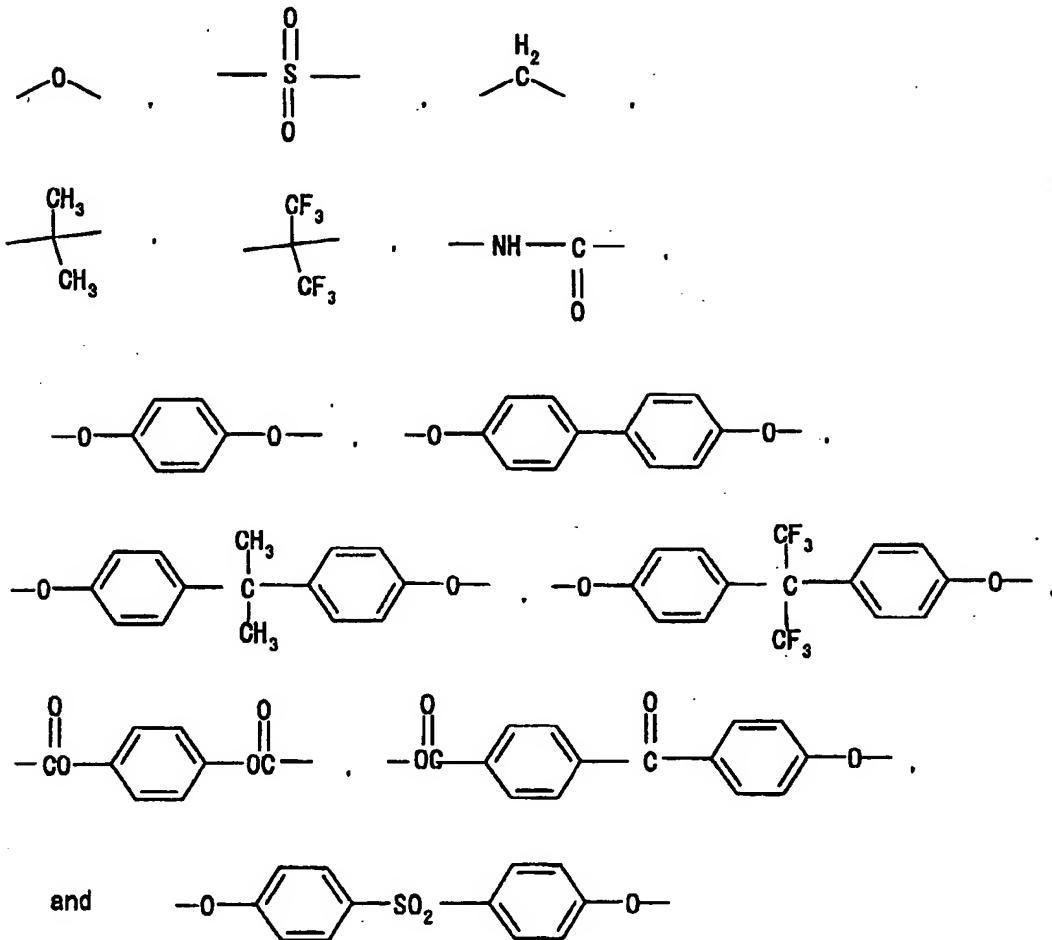
and

and each R<sup>3</sup> in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>); and

General Formula (3) is:



(where R<sup>4</sup> is a bivalent organic group selected from a group consisting of:



and each R<sup>5</sup> in the group is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>).

20. The polyimide film as set forth in Claim 19, the polyimide film having a thickness in a range of from 1 $\mu$ m to 200 $\mu$ m.

21. The polyimide film as set forth in Claim 19, the polyimide film having a modulus of elasticity in a range of from 500kg/mm<sup>2</sup> to 800kg/mm<sup>2</sup>.

22. The polyimide film as set forth in Claim 19, the polyimide film having a coefficient of hygroscopic expansion in a range of from 2ppm/%RH to 20ppm/%RH.

23. The polyimide film as set forth in Claim 19, the polyimide film having a coefficient of liner expansion in a range of 1 to  $30 \times 10^{-6}$ cm/cm/°C at a temperature of from 100°C to 200°C.

24. The polyimide film as set forth in Claim 19, wherein:

a peel strength at an interface between the polyimide

film and a metal layer of laminate is not less than 5N/cm, the laminate having the polyimide film and the metal layer that is formed on the polyimide film by vacuum depositing and electroplating; and

a retention rate of the peel strength is not less than 10% after exposing the laminate to environment of a temperature of 121°C and a humidity of 100%RH for 12 hours.

25. Laminate comprising:

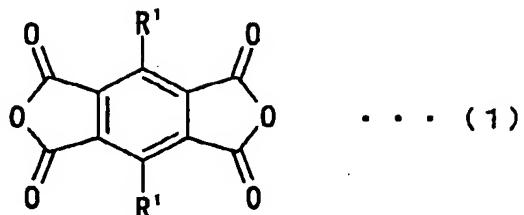
a metal layer; and

a polyimide film prepared by copolymerizing an acid dianhydride component and a diamine component,

the acid dianhydride component including the pyromellitic dianhydride, represented by General Formula (1), in a range of from 40 mole% to 80 mole%, the biphenyl tetracarboxylic dianhydride, represented by General Formula (5) in a range of from 1 mole% to 40 mole%, and the bis(trimellitic monoester anhydride), represented by General Formula (4), in a range of from 20 mole% to 50 mole%, and

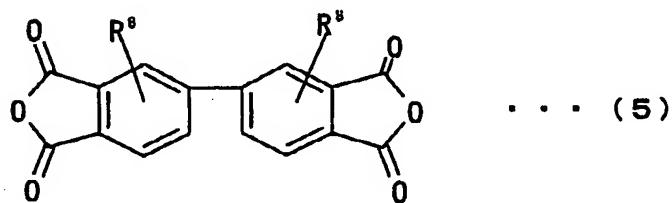
the diamine component including the paraphenylenediamine, represented by General Formula (2), in a range of 25 mole% to 75 mole%, and the diaminodiphenyl ether, represented by General Formula (3); in a range of 25

mole% to 75 mole%, where General Formula (1) is:



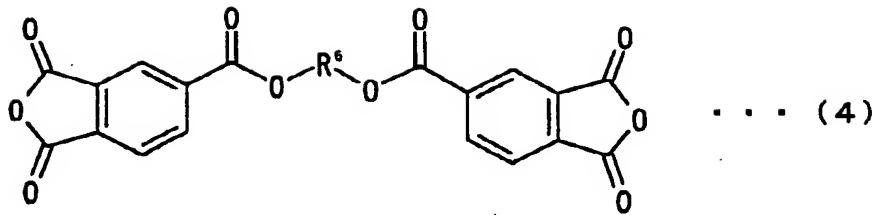
(where  $R^1$  is a residue selected from a group consisting of  $H^-$ ,  $CH_3^-$ ,  $CF_3^-$ ,  $Cl^-$ ,  $Br^-$ ,  $F^-$ , and  $CH_3O^-$ , and  $R^1$  may be the same residues or different residues);

General Formula (5) is:

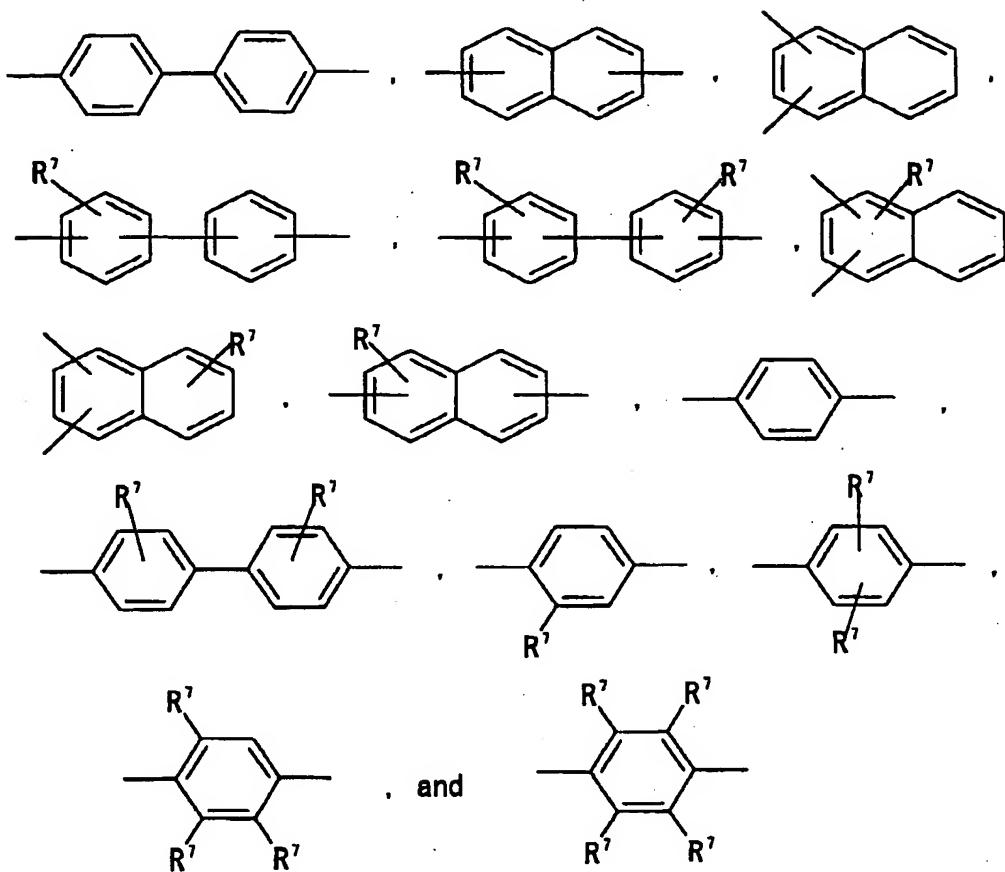


(where  $R^8$  is a residue selected from a group consisting of  $H^-$ ,  $CH_3^-$ ,  $Cl^-$ ,  $Br^-$ ,  $F^-$  and  $CH_3O^-$ , and  $R^8$  may be the same residues or the different residues);

General Formula (4) is:



(where  $R^6$  is a bivalent organic group selected from a group consisting of:

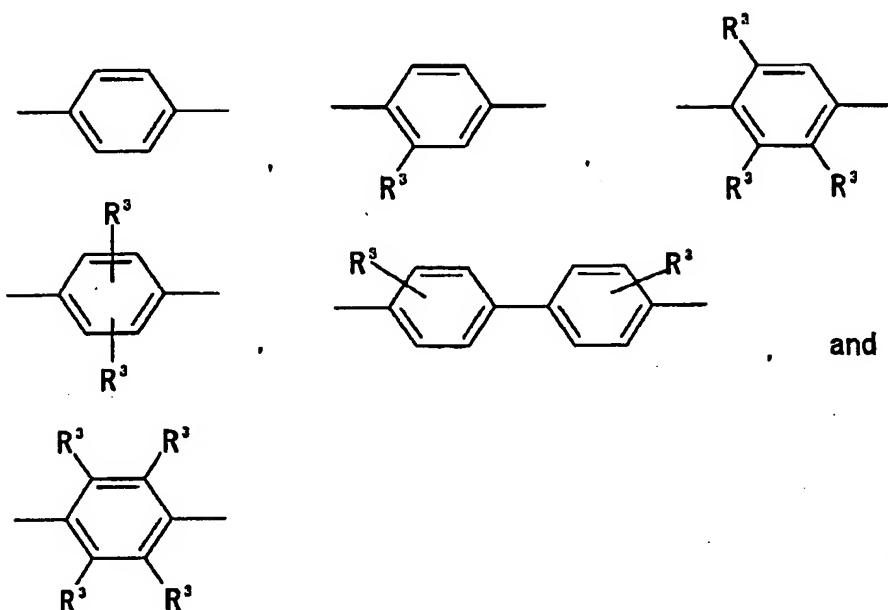


and each  $R^7$  is independently any one of -H, -CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, and -CO-NH<sub>2</sub>);

General Formula (2) is:

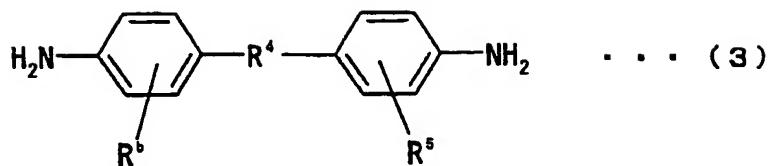


(where  $\text{R}^2$  is a bivalent aromatic group selected from a group consisting of:

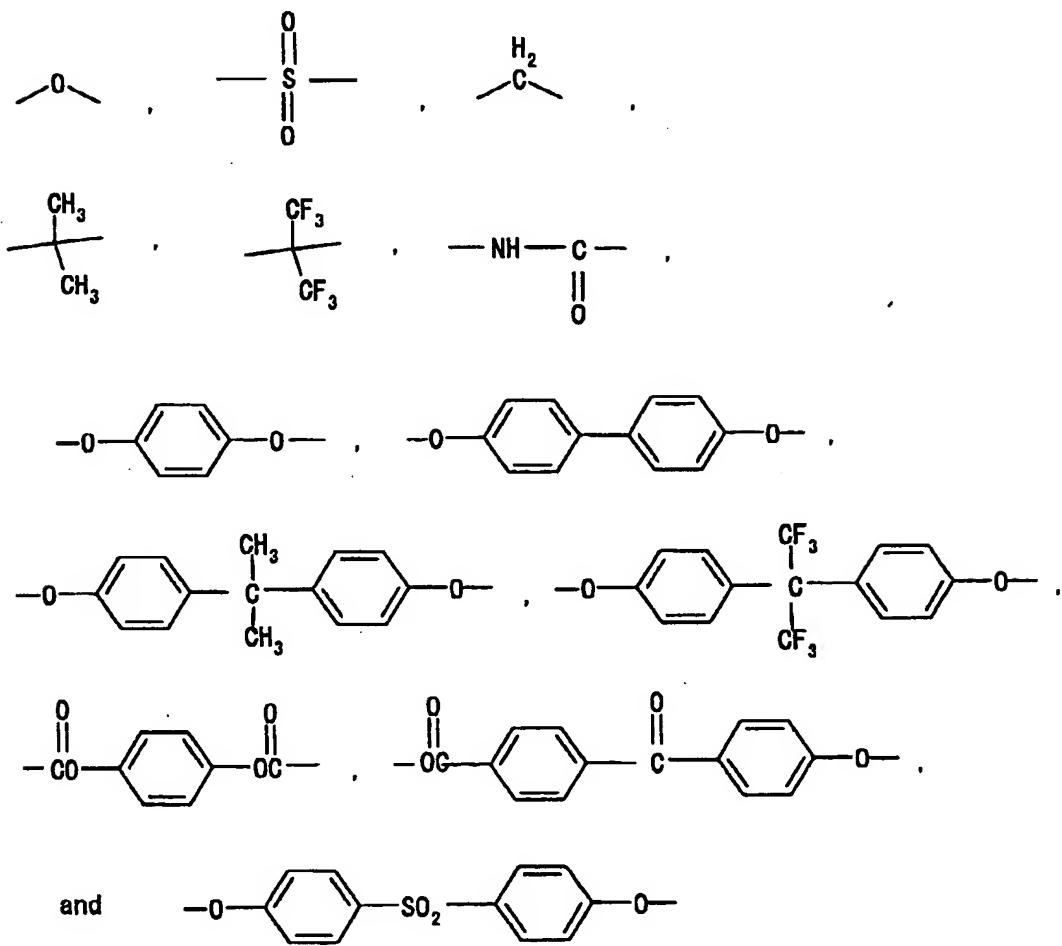


and each  $\text{R}^3$  in the group is independently any one of -H, - $\text{CH}_3$ , -OH, - $\text{CF}_3$ , - $\text{SO}_4$ , -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and -OCH<sub>3</sub>); and

General Formula (3) is:



(where  $\text{R}^4$  is a bivalent organic group selected from a group consisting of:



and each  $\text{R}^5$  in the group is independently any one of -H,

-CH<sub>3</sub>, -OH, -CF<sub>3</sub>, -SO<sub>4</sub>, -COOH, -CO-NH<sub>2</sub>, -Cl, -Br, -F, and  
-OCH<sub>3</sub>).